FORM 1449\*

## INFORMATION DISCLOSURE STATEMENT

Docket Number: 10873.1944USWO Application Number: 10/598,095

IN AN APPLICATION

(Use several sheets if necessary)

Applicant: KITAOKA, et al. /06

Filing Date: Herewith Group Art Unit: Unknown

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		U.S. F	PATENT DOCUMEN	NTS			
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING IF APPRO	DATE
/F.H./_	2004/183090	September, 2004	Kitaoka, et al.				
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	<u> </u>	FOREIG	N PATENT DOCUM	IENTS		<u> </u>	
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
H./	1-116013	Мау, 1989	Japan			Abstract	
.H./	2000-327495	November, 2000	Japan			Abstract	
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.H./	The Soc	ciety of Chemical Enginers, Japan, "Kagaku Kogaku Binran", vol. 6, 1999, pgs. 426-427					
	Kawamura, et al., "Growth of Transparent, Large Size GaN Single Crystal with Low Dislocations using Ca-P Flux System", Jpn. J. Appl. Phys., Vol. 42						
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PATENT TRADEMARK OFFICE

EXAMINER /Felisa Hiteshew/

DATE CONSIDERED 08/12/2008

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.